

PROCESS FOR COATING SUBSTRATES

ABSTRACT OF THE DISCLOSURE

The present invention relates to a process for coating a substrate by applying to a substrate a coating composition containing

- A) at least one compound which contains at least two (meth)acrylate groups and at least one isocyanate-reactive group and which is free from isocyanate groups and blocked isocyanate groups,
- B) at least one blocked polyisocyanate, which does not contain any ethylenically unsaturated groups and
- C) at least one photoinitiator,

curing the coating composition by the action of UV light and post-curing by increasing the temperature of the coating.